

Chemical routes to GeS₂ and GeSe₂ nanowires†Manashi Nath,^{a,b} Amitava Choudhury^{a,b} and C. N. R. Rao^{*a,b}^a Chemistry and Physics of Materials Unit, Jawaharlal Nehru Center for Advanced Scientific Research, Jakkur P. O., Bangalore-560 064, India. E-mail: cnrrao@jncasr.ac.in; Fax: +91 80 22082760^b Solid State and Structural Chemistry Unit, Indian Institute of Science, Bangalore-560 012, India

Received (in Cambridge, UK) 5th August 2004, Accepted 10th September 2004

First published as an Advance Article on the web 11th October 2004

Nanowires of GeS₂ and GeSe₂ have been obtained by novel chemical routes involving the decomposition of organo-ammonium precursors containing super-tetrahedral Ge₄S₁₀ and the dimeric Ge₂Se₆ units.

Nanowires of several inorganic materials including those of oxides, chalcogenides, nitrides and carbides have been synthesized and characterized by employing a variety of methods.^{1,2} Besides the well-known vapor-liquid-solid, vapor-solid (VS) and hydrothermal processes, ingenious chemical routes have been employed to generate these nanowires. Thus, nanowires of Fe₇S₈ have been produced recently by first preparing nanowires of its hybrid composite with ethylenediamine and decomposing the hybrid at low temperatures.³ An important aspect of nanoscience research today is to investigate mild chemical routes for the synthesis of one-dimensional nanostructures. We, therefore, considered it of interest to explore the synthesis of nanowires of GeS₂ and GeSe₂ both of which crystallize in layered structures. Knowing that the nanotubes of Mo and W dichalcogenides can be produced by the thermal decomposition of the ammonium chalcometallates containing tetrahedral MoS₄ and WS₄ units,⁴ we sought to make use of precursors containing super-tetrahedral adamantanoid-type Ge₄(S/Se)₁₀ units along with dimeric Ge₂(S/Se)₆ units formed by joining GeS/Se₄ tetrahedra,^{5,6} for the purpose. We have carried out the decomposition of the molecular precursors to obtain δ-GeS₂ and GeSe₂ nanowires. While δ-GeS₂ nanowires could be prepared from [TMA]₄Ge₄S₁₀ (TMA = tetramethylammonium), GeSe₂ nanowires were produced from a new organo-ammonium precursor, [(C₃H₇)₂NH₂]₄[Ge₂Se₆].‡

Ozin and co-workers⁷ first reported the structure of δ-GeS₂ formed by the acid hydrolysis of [TMA]₄[Ge₄S₁₀]. Controlled acid hydrolysis of [TMA]₄Ge₄S₁₀ in the presence of sodium dodecyl-sulfate (SDS), followed by refluxing in PEG-600 yielded δ-GeS₂ nanowires in high yield (> 80%).§ The SEM image in Fig. 1a shows nanowires with lengths exceeding several micrometers. EDX analysis showed the Ge : S ratio to be ~ 1 : 2. The TEM image in Fig. 1b shows the nanowires to have diameters in the 20–80 nm range and lengths of several microns. When the reaction mixture was refluxed for longer duration (6 h), the nanowires developed distortions and undulations. The high-resolution electron microscope (HREM) image in Fig. 1c shows the lattice fringes with an inter-layer separation of ~ 6 Å. The growth direction of the nanowires is along the <112> direction and there are very few defects in the nanowires. The good electron diffraction (ED) pattern (see inset A in Fig. 1c) shows spots due to the (213) reflection of δ-GeS₂ [JCPDS file, card no. 27-0239]. The Fourier transform (FFT) generated ED pattern given in inset B of Fig. 1c is comparable to the experimental pattern. The X-ray powder diffraction pattern of the nanowires agreed with that reported in the literature⁷ showing the first line at ~ 6 Å followed by an intense line at 3.88 Å and weaker reflections at 3.26 Å and 3.01 Å.

Acid hydrolysis of [TMA]₄Ge₄Se₁₀ gave selenium. Thermal decomposition of [TMA]₄Ge₄Se₁₀ yielded Se nanowires.⁸ We

therefore prepared a new organo-ammonium compound [(C₃H₇)₂NH₂]₄[Ge₂Se₆]¶ which on thermal decomposition yielded GeSe₂ nanowires. EDX analysis of the individual nanowires revealed a composition of 1 : 2 for Ge : Se and the XRD pattern was comparable to that of monoclinic GeSe₂. In Fig. 2a, we show a TEM image of GeSe₂ nanowires. The nanowires have a diameter of ~ 30 nm with lengths of a few microns. The nanowires were electron beam-sensitive and decomposed on prolonged exposure forming an amorphous covering. Fig. 2b shows a HREM image of a GeSe₂ nanowire. The image shows lattice fringes of ~ 5.8 Å corresponding to the separation between the (002) planes of monoclinic GeSe₂ which has a layered structure. The ED pattern (shown in the inset of Fig. 2b) shows the single crystalline nature of

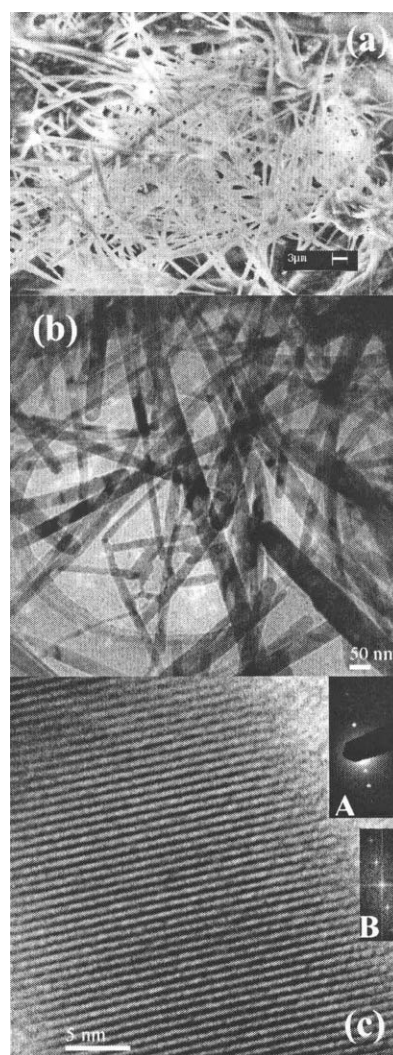


Fig. 1 (a) SEM and (b) low-magnification TEM image of the δ-GeS₂ nanowires; (c) HREM image of a nanowires showing the lattice fringes. Inset A shows the experimental SAED pattern obtained from the nanowires while inset B shows the FFT generated ED pattern.

† Electronic supplementary information (ESI) available: synthesis and characterisation details and Fig. S1 showing the structure of the molecular precursor [C₆H₁₄NH₂]₄[Ge₂Se₆] showing the [Ge₂Se₆] dimer and the amine. See <http://www.rsc.org/suppdata/cc/b4/b412056f/>

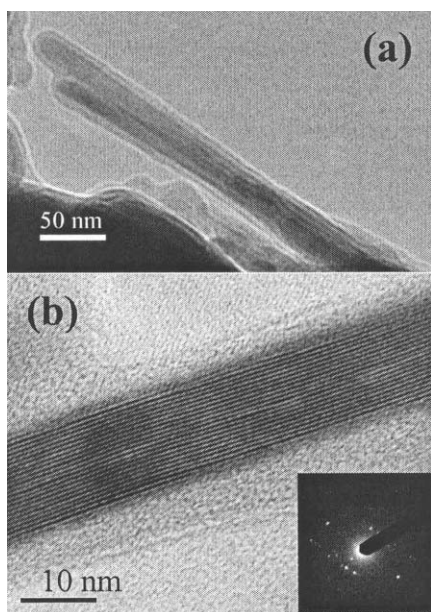


Fig. 2 (a) Low-magnification TEM image of the GeSe₂ nanowires; (b) HRTEM image of a GeSe₂ nanowire. The inset shows the typical ED pattern.

the wire and the spots could be indexed as (002), (200) and (142) planes of monoclinic GeSe₂ with a layered structure [$a = 7.016$, $b = 16.796$, $c = 11.831$ Å, JCPDS file card no. 30-0595].

The mechanism of formation of the δ -GeSe₂ and GeSe₂ nanowires can be understood as follows. δ -GeSe₂ is formed by the condensation polymerization of the Ge₄S₁₀⁴⁻ adamantanoid units which are present in the precursor, [TMA]₄Ge₄S₁₀ (see Fig. 3a). The adamantanoid moiety is an attractive precursor which can give rise to various architectures under appropriate reaction conditions. For example, in the presence of long-chain amines/surfactants the adamantanoid-type building blocks form lamellar structures,⁹ and microporous⁵ or mesoporous⁹ networks in the presence of transition metal ions. Furthermore, controlled hydrolysis of an organized assembly of Ge₄S₁₀⁴⁻ is known to form micro-crystals δ -GeSe₂ with an expanded framework structure.⁷ In the present case, the presence of a surfactant in the reaction mixture may trigger the condensation polymerization reaction in the micellar cavity formed by the surfactant molecules, leading to a confined reaction. The morphology of the final product would depend on the shape of the micellar cavity, a cylindrical cavity giving rise to one-dimensional nanostructures.¹⁰ [(C₃H₇)₂NH₂]₄[Ge₂Se₆], when heated under the gas flow, decomposes forming small clusters of GeSe₂. These clusters may aggregate under the gas flow to reduce the surface energy.¹¹ Oriented attachment of the aggregates can give rise to one-dimensional growth similar to that found in the case of ZnO nanorods grown in a colloid system under solvothermal conditions.¹² Accordingly, the decomposition of the organo-ammonium compound at lower temperatures or at a lower gas flow gave nanoparticles. The existence of Ge₂Se₆ dimers in the molecular precursor[¶] may facilitate the formation of GeSe₂ which contains dimeric Ge₂Se₆ units joining corner-shared chains of GeSe₄ tetrahedra (Fig. 3b).

Nanowires of δ -GeSe₂ and GeSe₂ have been synthesized by novel chemical routes starting from different molecular precursors containing the adamantanoid Ge₄S₁₀⁴⁻ and Ge₂Se₆⁴⁻ units respectively which are also present in the nanostructured product.

Notes and references

‡ Synthesis of precursors: The [TMA]₄Ge₄S₁₀ salt was prepared by the known hydrothermal procedure.¹³ [(C₃H₇)₂NH₂]₄[Ge₂Se₆] was prepared solvothermally from metallic Ge and Se powders heated in the presence of dipropylamine.¶ IR spectra, CHN and EDX analyses were used to confirm the chemical composition.

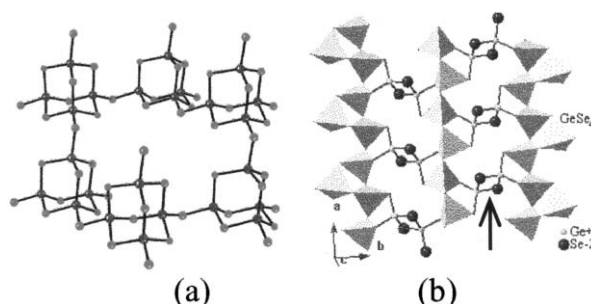


Fig. 3 (a) A part of the δ -GeSe₂ structure showing the linking of six Ge₄S₁₀ units; (b) a perspective view of the layer in GeSe₂, the Ge₂Se₆ dimer joining the two chains is marked by an arrow.

§ Synthesis of nanowires: In a typical reaction, 35 mg of SDS was dissolved in 1 ml of distilled water. 45 mg of [TMA]₄Ge₄S₁₀ was separately dissolved in 1.4 ml distilled water and added to the surfactant solution. 1.1 ml of freshly prepared 0.22 M HCl was then added to the reaction mixture with constant stirring. The reaction mixture turned turbid and the smell of H₂S liberated confirmed the onset of hydrolysis. Stirring was continued for about 1 h and the turbid solution was left standing overnight. The reaction mixture was then added to 12 ml PEG-600 solution and refluxed for 3 h. A dirty white fine precipitate adhering to the walls of the refluxing vessel, was separated by decanting the supernatant solution, washed with methanol and dried in air. Nanowires of GeSe₂ were obtained by the thermal decomposition of [(C₃H₇)₂NH₂]₄[Ge₂Se₆] in a horizontal tube-furnace heated to 450 °C under a flow of Ar (180 sccm) + H₂ (20 sccm). After the completion of the reaction, the furnace was cooled to room temperature and the blackish product containing GeSe₂ nanowires was collected from the sample boat (yield ~50%).

¶ The structure of the compound was determined with the help of single-crystal X-ray diffraction data. Crystal data for [(C₃H₇)₂NH₂]₄[Ge₂Se₆]: Empirical formula = C₁₂H₃₂GeN₂Se₃, $M_r = 513.87$, monoclinic, $P2_1/c$, $a = 10.8528(8)$, $b = 18.3953(14)$, $c = 10.9941(8)$ Å, $\beta = 103.42^\circ$, $V = 2134.9(3)$ Å³, $Z = 4$, $\mu = 6.540$ mm⁻¹. 8642 reflections measured and 3051 independent reflections, $R_{int} = 0.0671$, $R_1 = 0.0709$ and $wR_2 = 0.1128$ (observed data), $R_1 = 0.1124$ and $wR_2 = 0.1237$ (all data). The structure of this compound consists of the edge-shared dimer (Ge₂Se₆²⁻) formed by GeSe₄ tetrahedra which are assembled in the presence of dipropylammonium cation (see Fig. S1†), the latter balancing the charge of the anionic cluster. The synthesis and characterization including detailed X-ray crystallographic data are supplied as supplementary material. CCDC 247347. See <http://www.rsc.org/suppdata/cc/b4/b412056f/> for crystallographic data in .cif or other electronic format.

- 1 Y. Xia, P. Yang, Y. Sun, Y. Wu, B. Mayers, B. Gates, Y. Yin, F. Kim and H. Yan, *Adv. Mater.*, 2003, **15**, 353 and references therein.
- 2 C. N. R. Rao, F. L. Deepak, G. Gundiah and A. Govindaraj, *Prog. Solid State Chem.*, 2003, **31**, 5 and references therein.
- 3 M. Nath, A. Choudhury, A. Kundu and C. N. R. Rao, *Adv. Mater.*, 2003, **15**, 2098.
- 4 M. Nath, A. Govindaraj and C. N. R. Rao, *Adv. Mater.*, 2001, **13**, 283.
- 5 O. M. Yaghi, Z. Sun, D. A. Richardson and T. L. Groy, *J. Am. Chem. Soc.*, 1994, **116**, 807; H. Ahari, A. Garcia, S. Kirkby, G. A. Ozin, D. Young and A. J. Lough, *J. Chem. Soc., Dalton Trans.*, 1998, 2023.
- 6 C.-W. Park, M. A. Pell and J. A. Ibers, *Inorg. Chem.*, 1996, **35**, 4555; R. Blachnik and A. Fehlker, *Z. Kristallogr. - New Cryst. Struct.*, 2001, **216**, 215.
- 7 M. J. MacLachlan, S. Petrov, R. L. Bedard, I. Manners and G. A. Ozin, *Angew. Chem., Int. Ed.*, 1998, **37**, 2076.
- 8 U. K. Gautam, M. Nath and C. N. R. Rao, *J. Mater. Chem.*, 2003, **13**, 2845.
- 9 F. Bonhomme and M. G. Kanatzidis, *Chem. Mater.*, 1998, **10**, 1153; M. J. MacLachlan, N. Coombs and G. A. Ozin, *Nature*, 1999, **397**, 681; M. Wachlod, K. K. Rangan, M. Lei, M. F. Thorpe, S. J. L. Billinge, V. Petkov, J. Heising and M. G. Kanatzidis, *J. Solid State Chem.*, 2000, **152**, 21.
- 10 C. N. R. Rao, F. L. Deepak, A. G. Govindaraj, N. A. Gunari and M. Nath, *Appl. Phys. Lett.*, 2001, **78**, 1853.
- 11 G. Ge and L. E. Brus, *J. Phys. Chem. B*, 2000, **104**, 9573; R. L. Penn and J. F. Banfield, *Science*, 1998, **281**, 969.
- 12 C. Pacholsky, A. Kornowski and H. Weller, *Angew. Chem., Int. Ed.*, 2002, **41**, 1188.
- 13 L. Bowes, W. U. Huynh, S. J. Kirkby, A. Malek, G. A. Ozin, S. Petrov, M. Twardowski and D. Young, *Chem. Mater.*, 1996, **8**, 2147.